

SEARCHED			
Class	Sub.	Date	Exmr.
250	492.2	06/10/02	BES
"	492.1		
430	311	06/10/02	BES
"	966		
"	967		
353	99,38	06/10/02	BES
"	31,34		
"	37,98		
378	34,35	06/10/02	BES
"	84,85		
"	87,145		
"	-147		
250	46	06/10/02	BES

SEARCH NOTES (INCLUDING SEARCH STRATEGY)		
WEST Search Keywords:	Date	Exmr.
Projection + (multiple/plurals) near(light source) + EUV/extreme UV + lithography + multiple light source + pyramid	06/10/02	BES
New Search WEST: (illuminat ⁿ e near ² (multiple or plurals) near ² (light adj source ²)) and(extreme or vacuum or deep)near ³ (uV or ultra adj word))	12/10/02	BES
Internet search Keyword: "EUV + numerical aperture"	12/10/02	BES

INTERFERENCE SEARCHED			
Class	Sub.	Date	Exmr.
250	492.2		
"	492.1		
250	504R	12/10/02	BES
353	37,99		
355	66,67,70		